

September 11, 2023

IGI Report Number

Shape and Cutting Style

Description

Measurements

GRADING RESULTS

**ELECTRONIC COPY** 

LABORATORY GROWN DIAMOND REPORT

# LABORATORY GROWN DIAMOND REPORT

PROPORTIONS

LG598380988 Report verification at igi.org

#### LABORATORY GROWN DIAMOND REPORT

## **GRADING SCALES**

## CLARITY

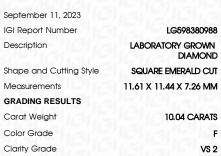
IF	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	l <sup>1-3</sup>
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

### COLOR

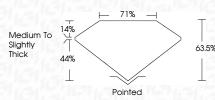
D E F G H I J Faint Very Light	Light
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1/571 LG598380988

Sample Image Used



LABORATORY GROWN DIAMOND REPORT

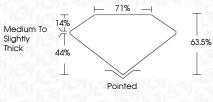


Polish	EXCELLENT		
Symmetry	EXCELLENT		
Fluorescence	NONE		
Inscription(s)	(G) LG598380988		
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment.			



Type IIa

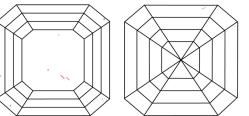
shape and curning sive	JOUARE
Measurements	11.61 X 11
GRADING RESULTS	
Carat Weight	
Color Grade	
Clarity Grade	



### ADDITIONAL GRADING INFORMATION



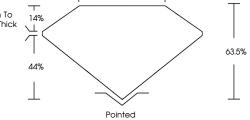
## **CLARITY CHARACTERISTICS**



### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

-Medium To 14% Slightly Thick  $\searrow$ LG598380988  $\overline{}$ 



71%

-

10.04 CARATS Carat Weight Color Grade F Clarity Grade VS 2

LABORATORY GROWN

SQUARE EMERALD CUT

11.61 X 11.44 X 7.26 MM

DIAMOND

## ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	131 LG598380988

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa



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